## Notic of References Cited Application/Control No. 09/469,652 Examiner B. William Baumeister Applicant(s)/Patent Under Reexamination WIERER ET AL. Page 1 of 1 U.S. PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
	Α	US-6,078,064	06-2000	Ming-Jiunn et al.	257/103
	В	US-5,760,423	06-1998	Kamakura et al.	257/99
	С	US-6,486,499	11-2002	Krames et al.	257/81
	D	US-			
	Е	US-			
	F	US-			
	G	US-			
	Н	US-			
	1	US-			
	J	US-		·	
	К	US-			
	L	US-			
	М	US-			

## **FOREIGN PATENT DOCUMENTS**

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification
	N					
	0					
	Р					
	Q					
	R					
	S					
	Т					

## **NON-PATENT DOCUMENTS**

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
	J	Brown et al., "Ohmic contacts to Si-implanted and un-implanted n-type GaN," Mat. Res. Soc. Symp. Proc. Vol. 395, 1996 Materials Research Society, pp. 855-860.
	٧	
	w	
	х	

A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).) Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.